## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

in re Application of:	)
Hiroshi YAMADA et al.	) ) Group Art Unit: 1795
Application No.: 10/587,315	) ) Examiner: Eoff, Anca
Filed: July 26, 2006	) )
For: PHOTOSENSITIVE RESIN COMPOSITION FOR LASER ENGRAVABLE PRINTING SUBSTRATE (as amended)	) Confirmation No.: 4548 ) )

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Sir:

## SUPPLEMENTAL REPLY

This supplemental reply is filed to supplement the reply filed March 2, 2010, and to correct translation errors appearing in the specification and claim 3.

Amendments to the Specification are included in this paper.

Amendments to the Claims are reflected in the listing of claims in this paper.

Remarks/Arguments follow the amendment sections of this paper.

Attachments to this amendment include Statement from a Translator.